English Translation of Amendments under PCT Article 34 filed on June $23,\,2004$



CLAIMS:

- 1. A field-effect transistor, comprising:
- a ferromagnetic layer, having a film thickness of 50 nm or less, which is made of a Ba-Mn oxide showing ferromagnetism at 0°C or higher;
- a dielectric layer made of a dielectric material or a ferroelectric material, said ferromagnetic layer and said dielectric layer being bonded to each other.
- 2. The field-effect transistor as set forth in claim 1, wherein the ferromagnetic layer is made of a Ba-Mn oxide whose composition is represented by (La_{1-x}Ba_x) MnO₃ where x satisfies 0.05<x<0.3.
- 3. The field-effect transistor as set forth in claim 1, wherein the ferromagnetic layer is made of a Ba-Mn oxide whose composition is represented by (La_{1-x}Ba_x) MnO₃ where x satisfies 0.10<x<0.3.
- 4. The field-effect transistor as set forth in claim 1, 2, or 3, wherein the dielectric material or the ferroelectric material is BaTiO₃, SrTiO₃, (Ba_{1-y}Sr_y) TiO₃, PbTiO₃, Pb (Zr1-zTiz) TiO₃, or Al₂O₃, where y satisfies 0<y<1 and z satisfies 0<z<1.
- 5. The field-effect transistor as set forth in claim 1, 2, or 3, wherein the dielectric material or the ferroelectric material is BaTiO₃, SrTiO₃, (Ba_{1-y}Sr_y) TiO₃, PbTiO₃, or Al₂O₃, where y satisfies 0<y<1.
- 6. The field-effect transistor as set forth in any one of claims 1 to 5, having a bottom-gate structure.